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Thermal and Optical Properties of COB Type LED Module Based on Al₂O₃ and AlN Ceramic Submounts

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Abstract: High power and high brightness light emitting diodes are penetrating into a number of lighting applications due to their excellent color saturation and long life characteristics. In this study, we used Aluminum Oxide (Al_2O_3) and Aluminum Nitride (AlN) as submount of LED chips and made Chip On Board (COB) type LED module utilizing eutectic bonder. The COB type LED module was made by using metal core printed circuit board and the flipchip on which metal solder was coated. We also fabricated COB type LED modules with epoxy and silicone resins as encapsulant, Al_2O_3 and AlN as substrates utilizing eutectic and epoxy die bonding methods. In these experiments the effect of AlN substrate was larger than other parameters for high power operation of LED modules.

Key words: Light emitting diode, ceramic, chip on board, module, encapsulation

INTRODUCTION

High Efficiency Light Emitting Diodes (LEDs) have been used successfully as the LED Back Light Unit (BLU) in the TFT-LCD industry and currently investigated actively for general lighting applications. Efficient thermal management of LEDs has become a critical issue in order to ensure both high efficiency and long lifetime of LED lightings operated with high input power (Biber, 2008; Liu et al., 2007).

High power and high brightness light emitting diodes are penetrating into a number of lighting applications due to their excellent color saturation and long life characteristics. However, the ability to prevent LEDs from overheating is a challenging task for thermal engineering designers. In order to ensure long lifetime and stable light output of LEDs the thermal performance parameters need to be designed in the LED chip package and module level, which include such items as heat sink structure and materials, interface materials and substrates.

Hu et al. (2008) presented the thermal and mechanical analysis of high power LEDs with ceramic packages. High level of thermo-mechanical stress was found in the LED chips made with ceramic packages although the mismatch of coefficient of thermal expansion was less than that with plastic packages. Hon et al. (2008) investigated high-power GaN LED chip and proposed a cheaper way to make a high power LED with lower thermal resistance. A new thermal management method was also proposed on silicone thermoelectric cooler integrated with high power LED. Chau et al. (2007) investigated the cooling enhancement design of LED through an electrohydrodynamic approach in which the forced convection of air was achieved by the ion wind due to gas discharge Biber (2008) also showed that the phenomenon. efficiency and reliability of the solid state lighting devices were strongly dependent on the successful management of heat evolved in the LED lighting systems.

In this study we used aluminum oxide (Al_2O_3) and Aluminum Nitride (AlN) as submount of LED chips and made Chip On Board (COB) type LED module utilizing eutectic bonder. The COB type LED module was made by using metal core printed circuit board and the flipchip on which metal solder was coated. The effects of these process parameters were investigated from the view point of heat management and high power operation of LED modules.

EXPERIMENTAL

Ceramic substrates: A key to high thermal conductivity substrate for LED is providing highly pure and dense ceramic material. For this purpose highly pure raw powder with total cation impurities less than 250 ppm and uniform particle size less than 1 pm was used. The hot press sintering technique was used for the fabrication of dense ceramic material with high thermal conductivity. The hot press sintering was carried out under a pressure of 100 kg cm⁻² at 1800°C for 2 h under 1 atm N₂. The hot pressed AlN ceramic substrate was found to have about 0.3 wt.% oxygen during the sintering process.

Figure 1 shows AlN and Al₂O₃ ceramic substrates made for LED packaging.

Packaging process: The structure of the LED module was specially designed to enhance the thermal performance as shown in Fig. 2. The junction pad was made as 5 mm circle



Fig. 1: Al₂O₃ (left, white) and AlN (right, gray) ceramic substrates for LED

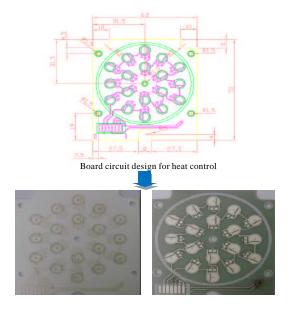


Fig. 2: The circuit design of LED modules made with Al₂O₃ (left) and AlN (right) ceramic submount

in consideration of the effective heat release and the wire-bonding interval of chip-pad. Each LED chip was placed at center of junction pad and each module was completed by wire bonding and cap sealing. The emission peak and dominant wavelength of LED chip used (Cree Co. Ltd.,) were 455 nm and 460 nm, respectively. The half bandwidth of chip was in the range of 22-24 nm. The total radiant flux of chip was in the range of 280-300 mW@350mA. Electrode had interval of 0.5 mm and line width of 1 mm to provide current to LED.

RESULTS AND DISCUSSION

Comparison of ceramic substrates: The AlN substrate has high thermal conductivity of 150 W/m.K at room temperature, which is seven times as high as that of Al₂O₃ substrate. The thermal expansion coefficient of the AlN is 4.5×10⁻⁶/°C, which is very close to that of the silicon semiconductor chip (3.4×10⁻⁶/°C) and much smaller than that of Al₂O₃ (Huang et al., 2007). This difference can reduce the stress problem induced by thermal expansion mismatches between the LED chip and ceramic submount in case of AlN substrate and also make it advantageous for mounting large size LED modules. The AlN substrate also has good electrical properties, that is, the electrical resistivity is 1×10¹⁴ Ω-cm and low dielectric constant almost as good as Al₂O₃ substrate. The AlN substrate shows not only higher mechanical strength but also easier machinable property than Al₂O₃ as shown in Table 1.

The eutectic bonding of LED chip was carried out at various temperatures. Figure 3 shows bonding strength between chip and substrate with time at various temperatures. From Fig. 3, it was noted that higher junction temperature induced stronger bonding between chip and substrate. However eutectic bonding temperature was set up at 320°C in this work from the view point of reducing thermal damage to LED chip.

Figure 4a-d and 5a-d show heat distribution of LED module with time. The thermal image maps were obtained with the thermographic camera (Flir Co. Ltd., T400). As shown in Fig. 4 and 5 AlN substrate showed better thermal conduction than Al_2O_3 substrate after driving the LED modules for 1 h.

Table 1: Comparison of Al₂O₃ and AIN substrates

Properties	Unit	Al_2O_3	AIN
Color	-	White	Gray
Bulk density	g cm ⁻³	3.78	3.32
Dielectric constant	@ 1MHz	9.8	8.8
Dielectric loss	-	0.0003	0.0003
Dielectric strength	$KV mm^{-1}$	15	25
Thermal conductivity	$\mathrm{W} \; \mathrm{m.k^{-1}}$	24	150
Thermal expansion coefficient	10-6/°C	6.8~7.3	4.5~4.9
Volume resistivity	W-cm	1013	1014
Flexural strength	MPa	400	400
Vickers hardness	HV10	1600	1200

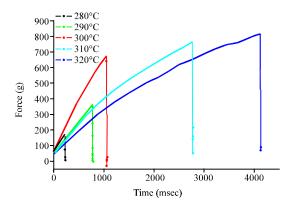


Fig. 3: Die bonding shear force between chip and substrate with time and temperature

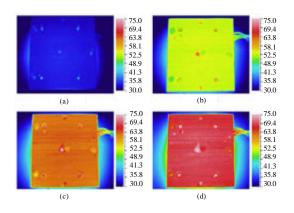


Fig. 4: (a-d) Heat distribution of LED module with Al_2O_3 substrate with time. (a) 10 min, (b) 30 min, (c) 50 min and (d) 60 min

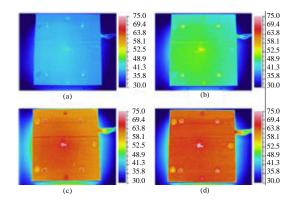


Fig. 5: (a-d) Heat distribution of LED module with AlN substrate with time. (a) 10 min, (b) 30 min, (c) 50 min and (d) 60 min

Effect of encapsulation materials: The heat dissipation is an important issue in the LED module as discussed in the

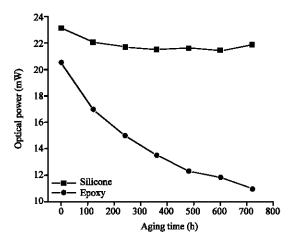


Fig. 6: Change of relative light power of the LEDs at 20 mA drive current over time

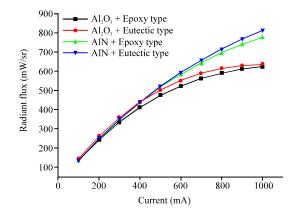


Fig. 7: Optical power of LED modules with current, die bonding type and substrate parameters

AlN and Al₂O₃ substrates. The choice of encapsulation material has also attracted much attention recently from the researchers of LED lighting from the view point of LED life time and efficiency.

The epoxy and silicone resins have been used as encapsulant in the packaging of LED module. In this study LED modules were packaged under optimum condition and process by using two different encapsulants, epoxy (DC-5260/DH-5260) and silicone (OE-6635) resins. The resulting LED modules were operated at a steady current 20 mA in the aging tests and total radiant flux was measured with time. The time when the light intensity attenuation reached 50% of the initial value was taken as the lifetime of the LED. It is seen from Fig. 5 that the lifetime of the LED module encapsulated with epoxy resin is about 720 h in this experiment which was conducted with UV LED as light source (Touloukian *et al.*, 1970). This relatively short life time can

be attributed to the yellowing of epoxy encapsulant under continuous exposure to the UV light. The silicone resin, however, had much less damage compared to epoxy resin, which could be explained by the presence of phenyl rings in the epoxy resin with high UV absorption property.

The optical power of LED modules on Al_2O_3 and AlN substrates was also studied according to the die bonding type with increasing current as shown in Fig. 7. The optical power was not dependant on the bonding type (Epoxy or Eutectic) to a large extent. However the effect of ceramic substrate was quite high, showing again the importance of the heat management in the LED module.

CONCLUSIONS

It was noted that the suitable thermal management is very important to achieve and guarantee optimal performance and reliability of the LED module. When LED modules were fabricated on aluminum oxide (Al₂O₃) and Aluminum Nitride (AlN) as submount, the latter exhibited much better thermal flow than the former as observed with the thermal imaging camera. We also fabricated COB type LED modules with epoxy and silicone resins as encapsulant, Al₂O₃ and AlN as substrates utilizing eutectic and epoxy die bonding methods. In these experiments the effect of AlN substrate was larger than other parameters for high power operation of LED modules.

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